

Application/Control No.	Applicant(s)/Patent under Reexamination
10/576,804	HWANG ET AL.
Examiner	Art Unit
LAYLA SOROUSH	1627

SEARCHED					
Class	Subclass	Date	Examiner		
424	401	8/13/2010	LS		

INTERFERENCE SEARCHED				
Class	Subclass	Date	Examiner	
525	94	8/13/2010	LS	
526	72	8/13/2010	LS	

SEARCH NO (INCLUDING SEARCH)
	DATE	EXMR
stic: composition claimed and odp	8/13/2010	LS
inventors search edan and east	8/13/2010	LS